

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

8/Pre-
Am. Ht
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In re Patent Application of:)
RAINERI ET AL.)
Serial No. Not Yet Assigned)
Filing Date: Herewith)
For: A METHOD FOR MANUFACTURING)
ISOLATING STRUCTURES)

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DATE OF DEPOSIT: February 20, 2002

NAME: Dawn Kimler

SIGNATURE: Dawn Kimler

PRELIMINARY AMENDMENT

Director, U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

Prior to the calculation of fees and examination of
the present application, please enter the amendments and
remarks set out below.

In the Drawings:

Submitted herewith is a request for a proposed
drawing modification as indicated in red ink to add a missing
reference numeral and to remove an extraneous marking from
FIG. 2. FIGS. 1 and 3-20 are also being modified as indicated
in red ink to remove extraneous markings therefrom.

In the Specification:

Please replace the paragraph beginning at page 2,
line 13, with the following rewritten paragraph:

-- One aspect of the invention is directed to a
method for forming isolating structures in a silicon carbide
layer. The method comprises depositing a masking layer on

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